Docket No.: 65933-067

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Customer Number: 20277

Isao HASEGAWA, et al.

Confirmation Number: 2729

Serial No.: 10/796,189

Group Art Unit: 2821

Filed: March 10, 2004

Examiner: not yet assigned

For:

WIRING STRUCTURE FORMED IN CONTACT HOLE, MANUFACTURING

METHOD THEREFOR, AND A DISPLAY APPARATUS HAVING THE SAME (AS

AMENDED)

INFORMATION DISCLOSURE STATEMENT

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the references listed on the attached form PTO-1449. It is respectfully requested that the references be expressly considered during the prosecution of this application, and that the references be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed within three months of the U.S. filing date OR before the mailing date of a first Office Action on the merits. No certification or fee is required.

Each non-English language reference was cited in a corresponding foreign application office action and its relevance discussed therein. A copy of the foreign office actions, together with an English language version thereof, is attached for the Examiner's information.

R0/796,189

The Foreign Patent documents JP 2000-277607 (with English Abstract) and JP 2000-

349298 (with English Abstract, previously cited in the Information Disclosure Statement, filed

on 6/28/04) were cited in the July 2, 2004 Office Action in corresponding JP Application 2002-

062670 (related Copending Application No. 10/383,058).

The Foreign Patent documents JP 10-170955, JP 11-111990 and JP 2000-236097, all

with English Abstracts, were cited in the June 1, 2004 Office Action in corresponding JP

Application 2002-059151 (related Copending Application No. 10/796,189).

Please charge any shortage in fees due in connection with the filing of this paper, including

extension of time fees, to Deposit Account 500417 and please credit any excess fees to such deposit

account.

Respectfully submitted,

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Date: August 17, 2004

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INFO	CIT	AT	ON DISCLOS ION IN AN ICATION	SURE	ATTY. DOCKET NO. 65933-067		SERIAL NO. 10/796,189		
SEP 2 0 2004					APPLICANT Isao HASEGAWA, et al.				
(PTO-1449) U.S. PATENT					FILING DATE March 10, 2004				
U.S. PATENT					T DOCUMENTS				
EXAMINER'S INITIALS	CITE NO.	Document Number Number-Kind Codez (7 known)		Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document		Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear		
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EXAMINER'S INITIALS	CITE NO.	Foreign Patent Document Country Codes -Number 4 -Kind Codes (if known)		Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Applicant of Cited Document Columns, Lines Where Relevant Figures		ion	
						Appear	Yes	No	
	-	 	JP 2000-277607	10/06/2000	TOSHIBA CORP.	 	JAPAN (w/English		
·							Abstract)		
			JP 10-170955	06/26/1998	FUJITSU LTD	<u> </u>	JAPAN (w/English Abstract)		
			JP 11-111990	04/23/1999	SANYO ELECTRIC CO LTD		JAPAN (w/English Abstract)		
			JP 2000-236097	08/29/2000	SEMICONDUCTOR ENERGY LAB CO LTD.		JAPAN (w/English Abstract)	·	
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)									
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^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

1 Applicant's unique citation designation number (optional). 2 Applicant is to place a check mark here if English language Translation is attached.